PTO/SB/30 (09-06)

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Request	Application Number	10/051,682
for	Filing Date	January 18, 2002
Continued Examination (RCE)	First Named Inventor	Robert Vincent Cox et al.
Transmittal		2142
Mail Stop RCE	Art Unit	
Commissioner for Patents P.O. Box 1450	Examiner Name	Ailes, Benjamin A.
Alexandria, VA 22313-1450	Attorney Docket Number	016295.0745
This is a Request for Continued Examination (RCE) under 37 CFR 1.114 of the above-identified application.  Request for Continued Examination (RCE) practice under 37 CFR 1.114 does not apply to any utility or plant application filed prior to June 8, 1995, or to any design application. See instruction Sheet for RCEs (not to be submitted to the USPTO) on page 2.		
<ol> <li>Submission required under 37 CFR 1.11d Nate: If the RCE is proper, any previously fled unestered amendments and amendments enclosed with the RCE will be entered in the order in which they were fled unless applicant flaturus otherwise. If applicant does not wish to have any previously filed unentered amendment(s) entered, applicant must request non-entry of such amendment(s).</li> </ol>		
Previously submitted. If a final Office action is outstanding, any amendments filed after the final Office action may be considered as a submission even if this box is not checked.		
i. Consider the arguments in the Appeal Brief or Reply Brief previously filed on		
li. Other		
b. 🗹 Endosed		
I. ✓ Amendment/Reply iii. Information Disclosure Statement (IDS)		
ii. Affidavit(s)/ Declaration(s)	iv. Other	
Miscellaneous       Suspension of action on the above-identified application is requested under 37 CFR 1.103(c) for a period of months. (Period of suspension shall not exceed 3 months; Fee under 37 CFR 1.17(i) required)     Other		
3. Fees The RCE fee under 37 CFR 1.17(e) is required by 37 CFR 1.114 when the RCE is filed.  The Director is hereby subnotized to charge the following fees, any underpayment of fees, or credit any overpayments, to Deposit Account No. 50-2148 https://dx.doi.org/10.1016/j.cc/10.1		
i. RCE fee required under 37 CFR 1.17(e)		
ii. Extension of time fee (37 CFR 1.136 and 1.17)		
iii.		
b. Check in the amount of \$enclosed		
c. Payment by credit card (Form PTO-2038 enclosed)		
WARNING: Information on this form may become public. Credit card information should not be included on this form. Provide credit card information and authorization on PTO-2038.		
	ANT, ATTORNEY, OR AGENT RE	EQUIRED
Signature  Name (Print/Type)   Anthony P Japoilelli	Date	
7 Polationy 1 : Idillitedia		istration No. 55,291
CERTIFICATE OF MAILING OR TRANSMISSION		
I hereby certify that this correspondence is being deposted with the United States Postal Service with sufficient postage as first class mail in an envelope admissed to: Mills Stop RCE, Commissioner for Patents, P. O. Box 1450. Alexandria, VA 22313-1450 or facsimile transmitted to the U.S. Patent and Trademark Office on the date shown below.		
Signature  Name (Print/Type)  Alfonso Juarez		April 5, 2007

This collection of information is required by 37 CFR 1.114. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO instruction or information in required by 3 LV LT 114. The air information is required to detain or relatin a benefit by the public which is to like (and by the USPTO) to process) an engliciant. Confidentiality is governed by \$S U.S.C. 122 and 37 CFR 1.11 and 1.14. The collection is estimated to take 12 minutes to complete, including spatienting, preparing, and submitting the completed applications from the the USPTO. Then will way depending upon the individual case. Any comments on the amount of time by unrelative to complete applications for reducing this bustone, though see that the third information Officer, U.S. Pattern and The amount of time by unrelative to the Complete applications for reducing the bustone, though see that the third information Officer, U.S. Pattern and The amount of the process of the complete applications for the process of the complete applications of the process of the complete applications of the process of